

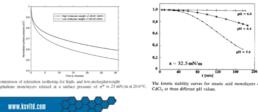


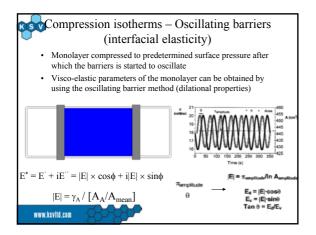
Compression isotherms – Relaxation isotherms (Stability)

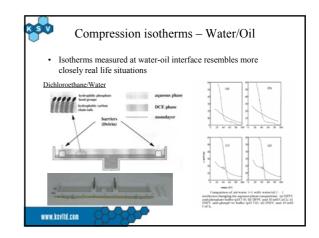
- Monolayer compressed to a predetermined pressure and then kept at this
- Monolayer compressed to a predetermined pressure at a certain area and then kept at constant area

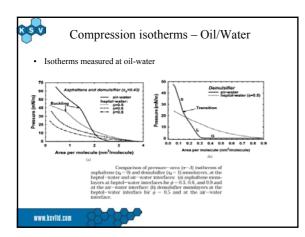
Constant pressure

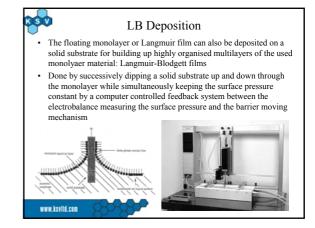


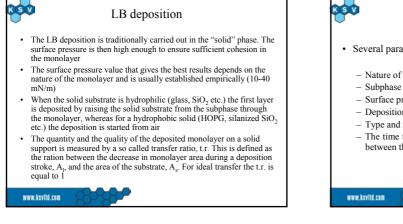






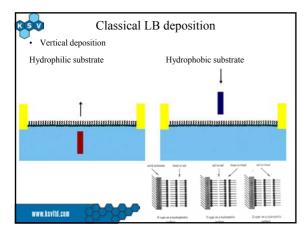


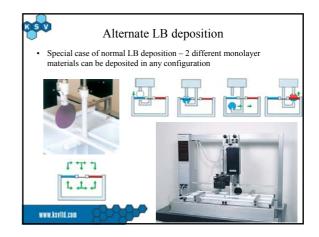


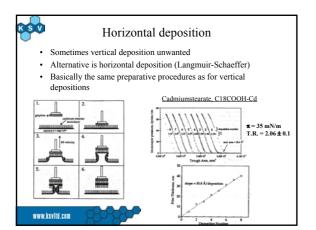


LB deposition

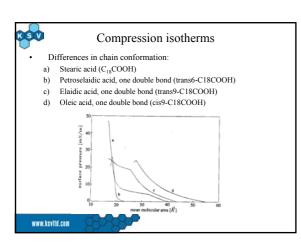
- · Several parameters affect what type of LB film is produced:
 - Nature of the spread film
 - Subphase composition, pH and temperature
 - Surface pressure during the deposition
 - Deposition speed
 - Type and nature of the solid substrate
 - The time the solid substrate is stored in air or in the subphase between the deposition cycles

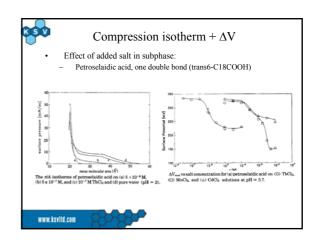


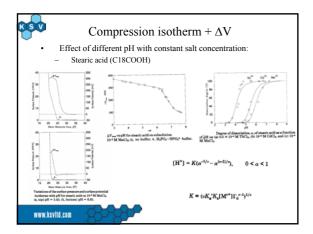


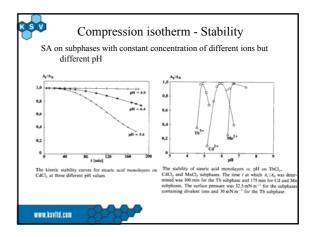


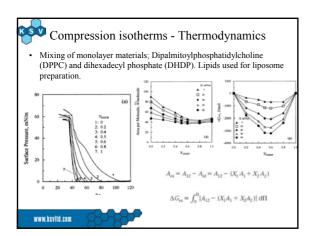


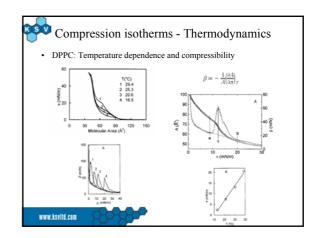


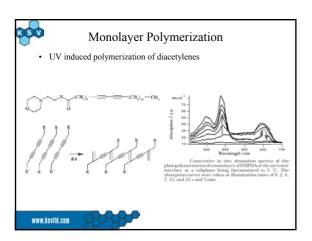


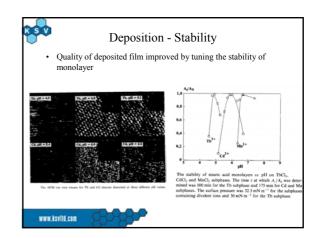


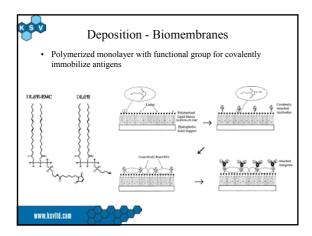


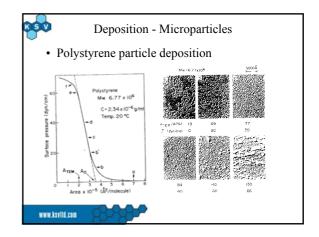


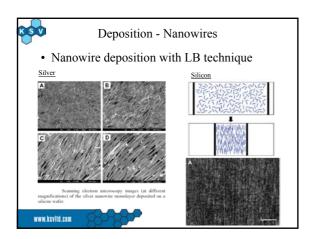


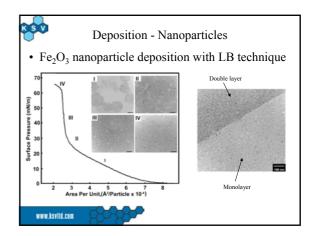


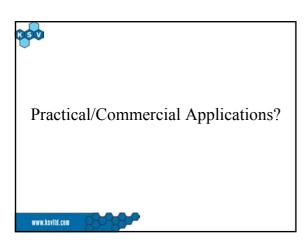




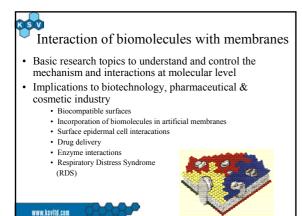


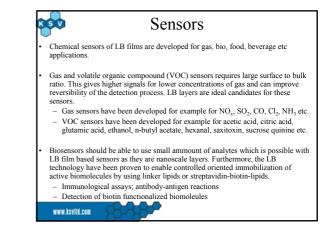






Basic properties of biomembranes Monolayers simple models of biological membranes Main components of mammalian plasma membrane and cell membranes are different lipids; phospholipids, sphingolipids, cholesterol etc. Studies with monolayers can help understanding the behaviour and role of different lipids in biological membranes



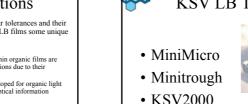




Technological Applications

- The capability of fabricating dimensions to mono-molecular tolerances and their ability to incorporate different molecular architecture give LB films some unique advantages for technological applications
 - Optical waveguides and signal processing devices based on thin organic films are being developed for computing and communications applications due to their nonlinear optical properties and fast respons times
 - Organic photoactive and/or conductive layers are being developed for organic light emitting diodes, organic solar cells, liquid crystal displays, optical information storage, optical switching etc.
 - CdS and TiO2 nanoparticles are studied due to their excellent photocatalytic properties.
 - Magnetic nanoparticles (magnetite Fe3O4 and maghemite Fe2O3) are of great interest for applications in information storage systems, catalysts, ferrofluids, and medical diagnostics
 - Nanoparticles and -wires are being used as templates for nanoscale photoresists Hybrid materials of clays and amphiphilic cations are being studied for ion-exchange materials and catalysis applications



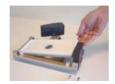




KSV MiniMicro

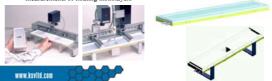
- The smallest miniaturized Langmuir/Langmuir-Blodgett trough on the market
- Standard trough size: 170 mm (l) x 80 mm (w) x 5 mm (d) = 68 ml other trough sizes by request
- Transportable and quick setup; exchangable troughs for modularity
- Full size software enabling all most common Langmuir film studies from compression (expansion) isotherms, isobars, dilational elasticity and Langmuir-Blodgett deposition
- Maximum substrate size for deposition; 25 mm (w) x 30 mm (l)
- Compatible with major thin film characterization techniques: Brewster Angle Microscopy, Fluoresence Microscopy, UV-Vis, IRRAS and Synchrotron beam line measurements of floating monolayers





KSV MiniTrough

- The most sold Langmuir/Langmuir-Blodgett trough system in the world
- Cost efficiency without compromize
- Standard trough size: 330 mm (l) x 75 mm (w) x 5 mm (d) = 125 ml, other trough sizes by request
- Low volume (from 15 ml), oil/water, microscopy, enzyme kinetics trough options
- Full size software enabling all most common Langmuir film studies from compression (expansion) isotherms, isobars, dilational elasticity and Langmuir-Blodgett deposition
- Maximum substrate size for deposition; 35 mm (w) x 60 mm (l)
- Compatible with major thin film characterization techniques; Brewster Angle Microscopy, Fluoresence Microscopy, UV-Vis, IRRAS and Synchrotron beam line measurements of floating monolayers



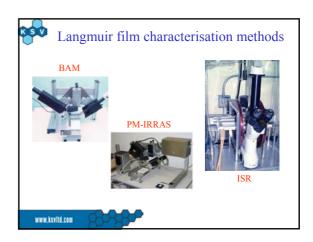


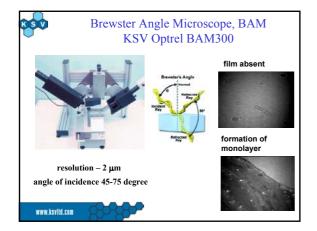
KSV 2000

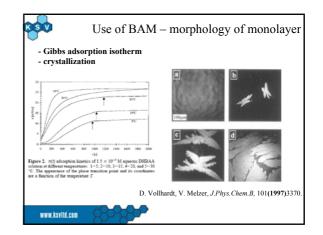
 The cost effective, full size modular and open design Langmuir/Langmuir-Blodgett trough system

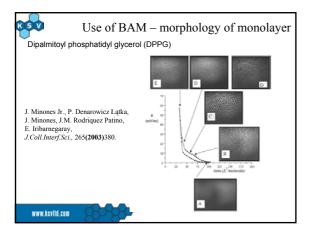
- Expands from a full size conventional Langmuir film balance to a high performance Langmuir film deposition system or to a fully equipped alternating multilayer Langmuir-Blodgett instrument; MiniAtternate Option (trough volume 1 L instead of 6 L)
- Compatible with all the special trough options of the KSV MiniTrough
- Standard trough size; 580 mm (l) x 150 mm (w) x 7 mm (d) = 610 ml
- Full size software enabling all most common Langmuir film studies from compression (expansion) isotherms, isobars, dilational elasticity and Langmuir-Blodgett deposition
- Maximum substrate size for deposition; 100 mm (w) x 100 mm (l)
- Compatible with most thin film characterization techniques; Brewster Angle Microscopy UV-Vis and IRRAS measurements of floating monolayers

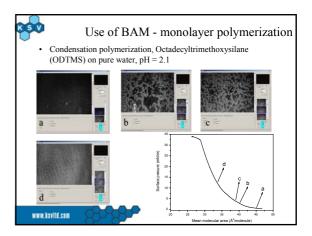


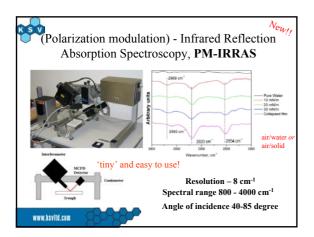


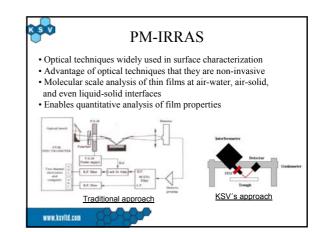














IRRAS vs PM-IRRAS

• Reference spectrum taken without a sample (e.g. clean subphase) is used to resolve sample's response from instrument's spectrum

PM-IRRAS

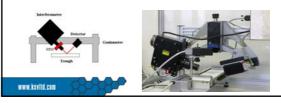
- Utilizes the fact that light's polarization state changes in reflection thus yielding differing spectra for differing polarization states
- Since atmospheric disturbance (H20 and CO2) is isotropic, i.e. has no polarization preference, its contribution to IRRAS measurement can be greatly reduced

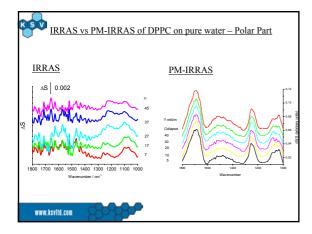
www.ksvitd.com

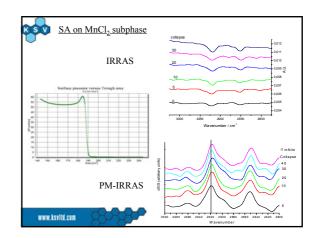


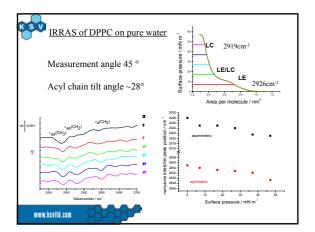
PM-IRRAS

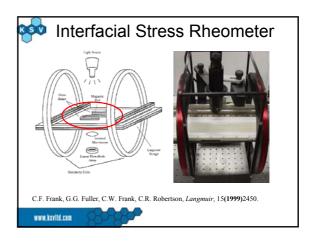
- Usual choice is to modulate polarization between s and p –states and record spectra for both states S_s and S_p
- Define differential reflectivity spectrum $\Delta S/S = (S_s S_p)/(S_s + S_p)$
- Isotropic disturbance is in theory cancelled out from differential spectrum
- · Sample's isotropic absorption cancelled

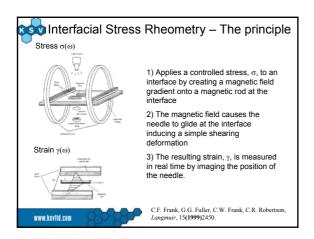


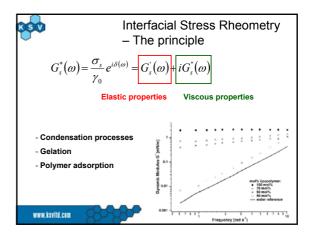


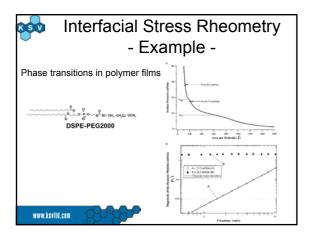


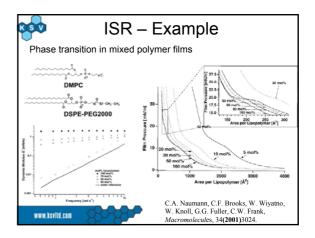


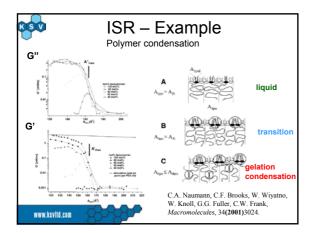


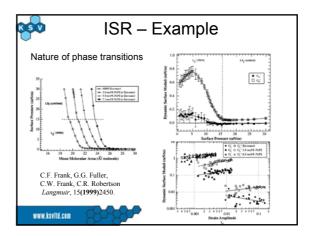




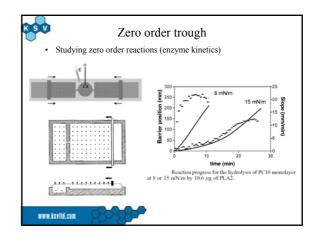
















Big Dipping trough 30×30 cm²



Mini Alternate for KSV2000 and KSV5000 -1.5 L of subphase only - max. substrate size 45 × 45 mm



An alternate trough for 6" Wafers has also been done !!!

